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Patent Application No. 10/715,326
Customer Number: 42717

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Yu-Liang Lin, et al.	§	Docket No.:	24061.51 (2002-1216)
Serial No.:	10/715,326	§	Examiner:	Thanh T. Nguyen
Filing Date:	November 17, 2003	§	Art Unit:	2813
For:	Supercritical Water Application for Oxide Formation	§	Conf. No.:	5111
		§		

RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop: Amendment
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed April 18, 2005, applicant hereby elects Group I, Claims 1-17, which is drawn to a method for fabricating an insulating layer on a substrate.

Applicant's election is made with traverse on the grounds that the embodiments delineated by the examiner are not patentably distinct and therefore constitute a single invention concept.

An early action on the merits is respectfully requested.

Respectfully submitted,

David M. O'Dell
Reg. No. 42,044

Date: 5-11-05

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CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Mail Stop: Amendment, Commissioner For Patents, PO Box 1450, Alexandria, VA 22313-1450 on the date below.

Bonnie Boyle
Name
5-11-05
Date